

500.41298X00/W0274-01EF

**EXPEDITED PROCESSING REQUIRED UNDER 37 CFR §1.116****IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant : Muneo FURUSE *et al.*  
Serial No. : 10/085,002  
Filed : 01 March 2002  
For : PLASMA ETCHING METHOD  
Art Unit : 1765  
Examiner : Duy Vu Nguyen Deo  
Conf. No. : 1139

**RECEIVED**  
**CENTRAL FAX CENTER**  
**FEB 02 2005**

OK to enter  
(initials)

**AMENDMENT AFTER FINAL REJECTION**

**Mail Stop AF**  
**Commissioner for Patents**  
**POB 1450**  
**Alexandria, Virginia 22313-1450**

2 February 2005

Sir:

In response to the Office Action having a USPTO mailing date of 2 November 2004, the following amendments and remarks are respectfully submitted in connection with the above-identified application.

In accordance with 37 CFR §1.121 in the Final Rule effective 30 July 2003, and as revised in the Final Rule effective 21 October 2004, each section of amendment begins on a new page, and changes are shown by strike-through (or double brackets where appropriate) and underlining to indicate deletions and additions, respectively. A complete listing of all claims ever presented in the application is given with the current status of each claim, and only the text of all pending and withdrawn claims is presented in full, with those pending/withdrawn claims not being amended herein being presented in clean version.